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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/750,246	12/29/2000	Dong Yeung Kwak	8733.371.00	7372
30827 7:	590 01/31/2003			
MCKENNA LONG & ALDRIDGE LLP			EXAMINER	
1900 K STREET, NW WASHINGTON, DC 20006			TON, MINE	I TOAN T
			ART UNIT	PAPER NUMBER
			2871	
			DATE MAILED: 01/31/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	1				
	09/750,246	KWAK ET AL.					
Office Action Summary	Examin r	Art Unit	_				
	Toan Ton	2871					
Th MAILING DATE of this communication appeariod for Reply	pears on the cover sh et with the	correspondenc address					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statut - Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b). Status	136(a). In no event, however, may a reply be oly within the statutory minimum of thirty (30) dwill apply and will expire SIX (6) MONTHS from the cause the application to become ABANDON	timely filed ays will be considered timely. m the mailing date of this communication. IED (35 U.S.C.§ 133).					
1) Responsive to communication(s) filed on 22	November 2002 .						
2a)⊠ This action is FINAL . 2b)□ TI	his action is non-final.						
3) Since this application is in condition for allow closed in accordance with the practice under	vance except for formal matters, r Ex parte Quayle, 1935 C.D. 11,	prosecution as to the merits is 453 O.G. 213.					
Disposition of Claims							
4)⊠ Claim(s) <u>1-24</u> is/are pending in the applicatio							
4a) Of the above claim(s) is/are withdra	awn from consideration.						
5) Claim(s) is/are allowed.	Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-24</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/o	or election requirement.						
Application Papers	or						
9) ☐ The specification is objected to by the Examination ☐ The drawing(s) filed on is/are: a) ☐ acce		raminer					
Applicant may not request that any objection to the							
11) The proposed drawing correction filed on							
If approved, corrected drawings are required in re		•					
12) The oath or declaration is objected to by the E							
Priority under 35 U.S.C. §§ 119 and 120							
13) Acknowledgment is made of a claim for foreig	n priority under 35 U.S.C. § 119	(a)-(d) or (f).					
a) ☐ All b) ☐ Some * c) ☐ None of:							
1. Certified copies of the priority documen							
2. Certified copies of the priority documen							
Copies of the certified copies of the price application from the International Beaution * See the attached detailed Office action for a list.	ureau (PCT Rule 17.2(a)).						
14) Acknowledgment is made of a claim for domes							
a) The translation of the foreign language pr							
15) Acknowledgment is made of a claim for domes							
Attachment(s)	Λ Π h. · · · · ·	(DTO 442) B N-(-)					
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 	5) Notice of Informa	ary (PTO-413) Paper No(s) al Patent Application (PTO-152)					
S. Debart and Trademark Office							



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Art-Unit: 2871

Claim Rejections - 35 USC § 103

1. Claims 1-24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art (APA hereinafter, Figures 1-6) in view of Nakahara et al (US 5982470).

APA discloses all except for gate dummy patterns and data dummy patterns.

Nakahara discloses the use dummy patterns within the same context as Applicant's claimed invention yield advantages such as uniform thickness of the seal on four sides, a difference in brightness between a central portion and portion in a vicinity of the seal in the display region can be eliminated. Therefore, it would have been obvious to one of ordinary skill in the art to employ such dummy patterns for achieving advantages such as uniform thickness of the seal on four sides, a difference in brightness between a central portion and portion in a vicinity of the seal in the display region can be eliminated.

Per claims 2-3, 6-7, 10, 11, 14-15, 18-19 and 22-23, it would have been *at least* obvious to one of ordinary skill to manufacture employing same steps or/and same materials for achieving several common reasons in the art such as cost-reduction(effective).

2. Claims 1-24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art (APA hereinafter, Figures 1-6) in view of Hayakawa et al (US 6172732).

APA discloses all except for gate dummy patterns and data dummy patterns.

Hayakawa discloses the use dummy patterns within the same context as Applicant's claimed invention yield advantages such as an unevenness of liquid crystal cell gap is improved. Therefore, it would have been obvious to one of ordinary skill in the art to employ such dummy patterns for achieving advantages such as an unevenness of liquid crystal cell gap is improved.



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Per claims 2-3, 6-7, 10, 11, 14-15, 18-19 and 22-23, see detailed explanations above.

Response to Arguments

3. Applicant's arguments filed 11-22-02 have been fully considered but they are not persuasive.

Applicant's arguments are as follows:

- (1) Nakahara fails to cure the deficiencies of Applicant's Figures 1-6.
- (2) Hayakawa fails to cure the deficiencies of Applicant's Figures 1-6.
- (3) Neither reference teaches gate dummy patterns.
- (4) The application comprises a method of irradiating a film by scanning it more than once so that a portion of the beams overlap in the energy slope regions.

Examiner's responses to Applicant's arguments are as follows:

(1) APA discloses all except for gate dummy patterns and data dummy patterns.

Nakahara discloses the use dummy patterns within the same context as Applicant's claimed invention yield advantages such as uniform thickness of the seal on four sides, a difference in brightness between a central portion and portion in a vicinity of the seal in the display region can be eliminated. Therefore, it would have been obvious to one of ordinary skill in the art to employ such dummy patterns for achieving advantages such as uniform thickness of the seal on four sides, a difference in brightness between a central portion and portion in a vicinity of the seal in the display region can be eliminated.



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- (2) APA discloses all except for gate dummy patterns and data dummy patterns.

 Hayakawa discloses the use dummy patterns within the same context as Applicant's claimed invention yield advantages such as an unevenness of liquid crystal cell gap is improved.

 Therefore, it would have been obvious to one of ordinary skill in the art to employ such dummy patterns for achieving advantages such as an unevenness of liquid crystal cell gap is improved.
- (3) Both references disclose a liquid crystal display device employing dummy patterns, wherein the use of dummy patterns yields several advantages such as a difference in brightness between a central portion and portion in a vicinity of the seal in the display region can be eliminated (Nakahara), an unevenness of liquid crystal cell gap is improved (Hayakawa).
- (4) Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims.

Conclusion

4. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event,

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however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Contact Information

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to T. TON whose telephone number is (703) 305-3489. Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

January 28, 2003

PRIIVIARY EXAMINER